

Micro channel cooling for tracking detectors.

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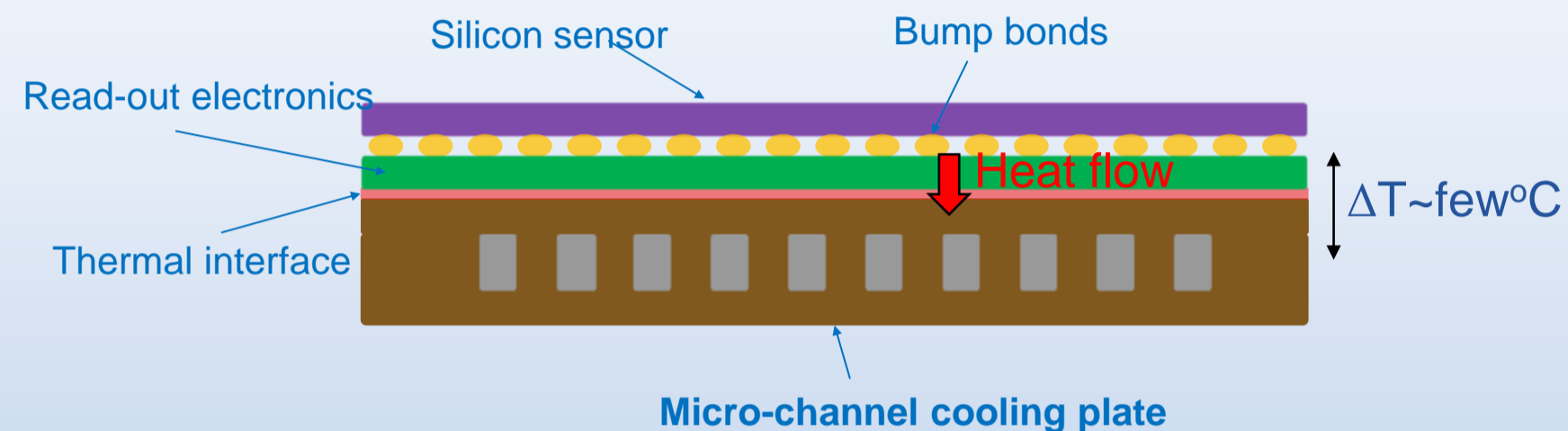
HEP vertex detectors: thermal management challenge

- Very high track densities and rates impose pixel sensors, with readout ASICs dissipating up to $\sim 2 \text{ W/cm}^2$.
- Very high irradiation doses $O(10^{16}) \text{ N}_{\text{eq}}/\text{cm}^2$:
 - require high voltage biasing ($\sim 1 \text{ kV}$) and causes high power dissipation in sensors up to $\sim 1 \text{ W/cm}^2$.
 - require sensor temperature $< -20 \text{ }^\circ\text{C}$ to avoid thermal runaway and detrimental annealing.
- Material for cooling must add **minimal X/X_0** .
- Thermal management is a key aspect to consider early in the design and integration of the present and future generation of Vertex detectors.
- Micro channel cooling is a novel method meeting the above requirements.

What is “microchannel cooling”?

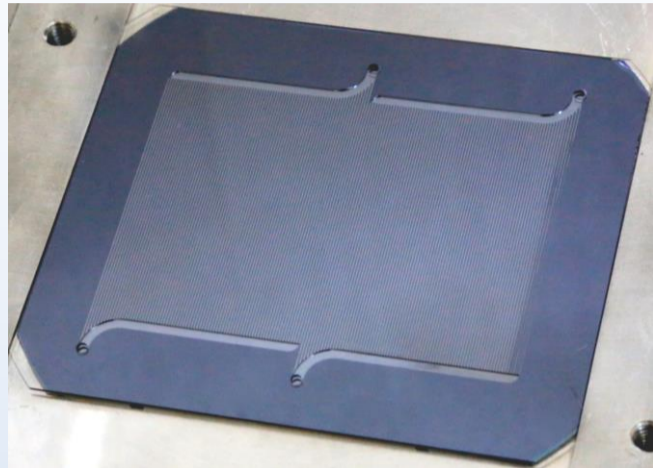
Use of a μ fluidics device as a heat exchanger.

- Refrigerant is brought immediately underneath the heat source.
 - > minimal thermal resistance and temperature gradient



- Advantages:
 - Low mass : because the cooling substrate also serves as mechanical support.
 - No mismatch of thermal expansion coefficients (CTE) if sensors, ASIC and cooling substrate are silicon: -> No mechanical stress caused by ΔT .
- Large variety:
 - channel dimensions 10 μm ... $\ll 1\text{mm}$,
 - single or multichannel layout
 - mono or two-phase heat absorption.
 - refrigerants: CO_2 , NH_3 , water, C_4F_{10} ...
 - substrate material: Polyimide, glass, Silicon, ceramic,...
- Not unique to HEP: many other industrial application fields
 - μ fluidics : cell development, lab-on-chip, ... (low pressure & very low flows)
 - heat exchanger : photonics IC, concentrated photovoltaic cells ,... (up to $100\text{W}/\text{cm}^2$!)

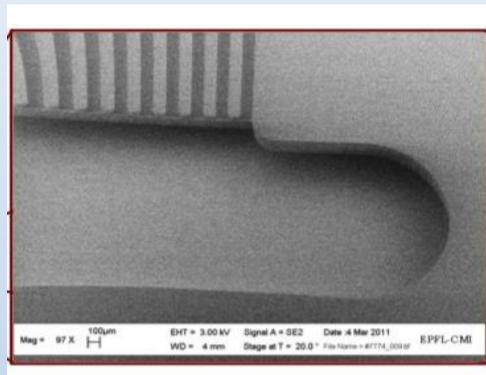
Si μ channel Projects in HEP



NA62 – GigaTracker «GTK»

- 0.13% X/X_0
- $T_{\text{sensor}} < -20\text{ }^\circ\text{C}$
- C_6F_{14} single phase
- 2.5 W/cm²
- Total power up to max 144 W
- In vacuum

«GTK»



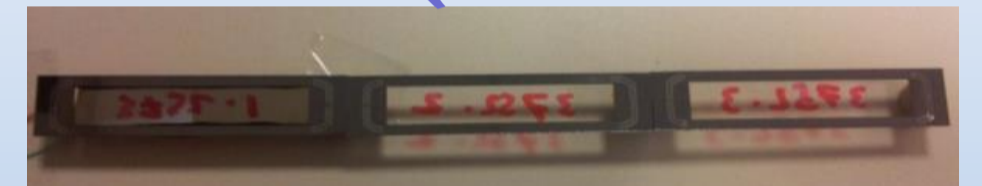
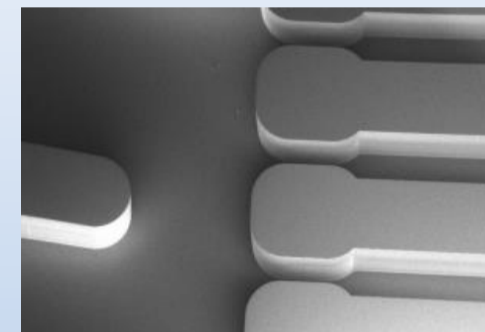
✓
Installing now



ALICE - ITS

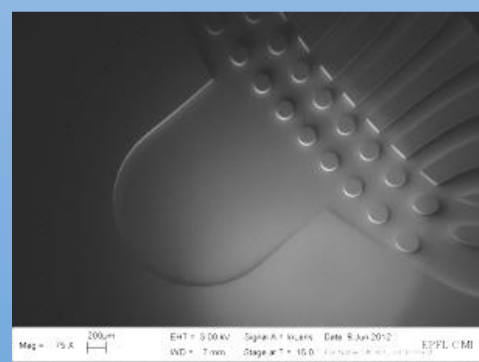
- No material in beam area
- $15 < T_{\text{sensor}} < 30\text{ }^\circ\text{C}$
- C_4F_{10} two-phase
- 0.1 W/cm²
- Total power 170 W

Under development
(backup option)



LHCb – Velo Upgrade

- Reduced material in beam area
- $T_{\text{sensor}} < -20\text{ }^\circ\text{C}$
- CO_2 two-phase
- 1.8 W/cm²
- Total power 1.9 kW
- In vacuum

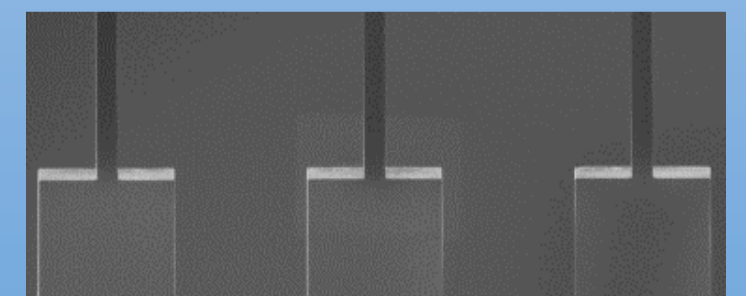
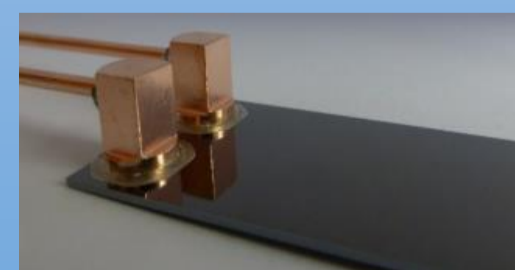


✓
Approved by
experiment

ATLAS - Phase II pixel

- Reduced material in beam area
- Refrigerant $< -30\text{ }^\circ\text{C}$
- CO_2 two-phase
- 0.4 W/cm²
- Total power: ~40kW (10m²)

Institutes interested



Micro-Fabrication of Si micro channels

Process steps involved :

Photolithography
plasma etching (DRIE)
Bonding: anodic, direct bonding ,...
Thinning
Thin Films deposition
Metrology

Many MEMS production facilities : e.g.

LETI (Grenoble)
CMI at EPFL (Lausanne)
CSEM(Neuchatel)
Nanofabrication centre (Southampton)
TMEC (Thailand)

Device size is limited to wafer size:

4", 6" or 8"



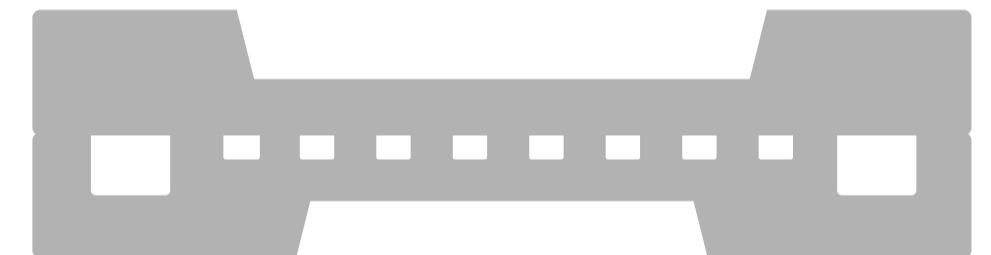
DRIE etching of manifold



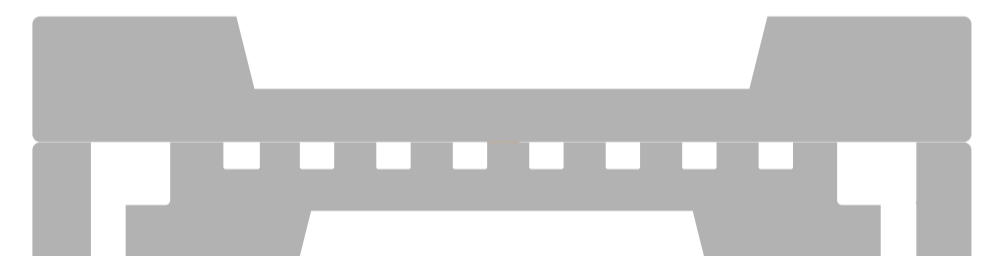
DRIE etching of channels



Si - Si direct bonding



Localized thinning

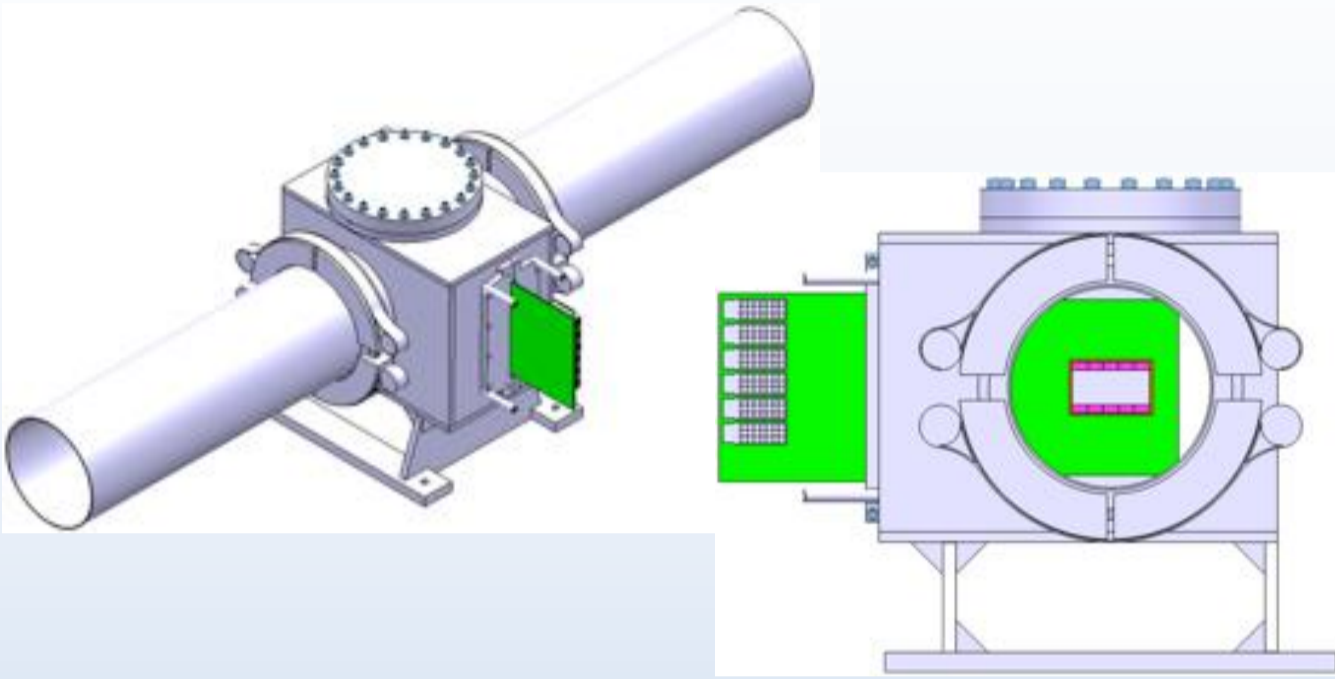


Plasma etching of fluidic inlets

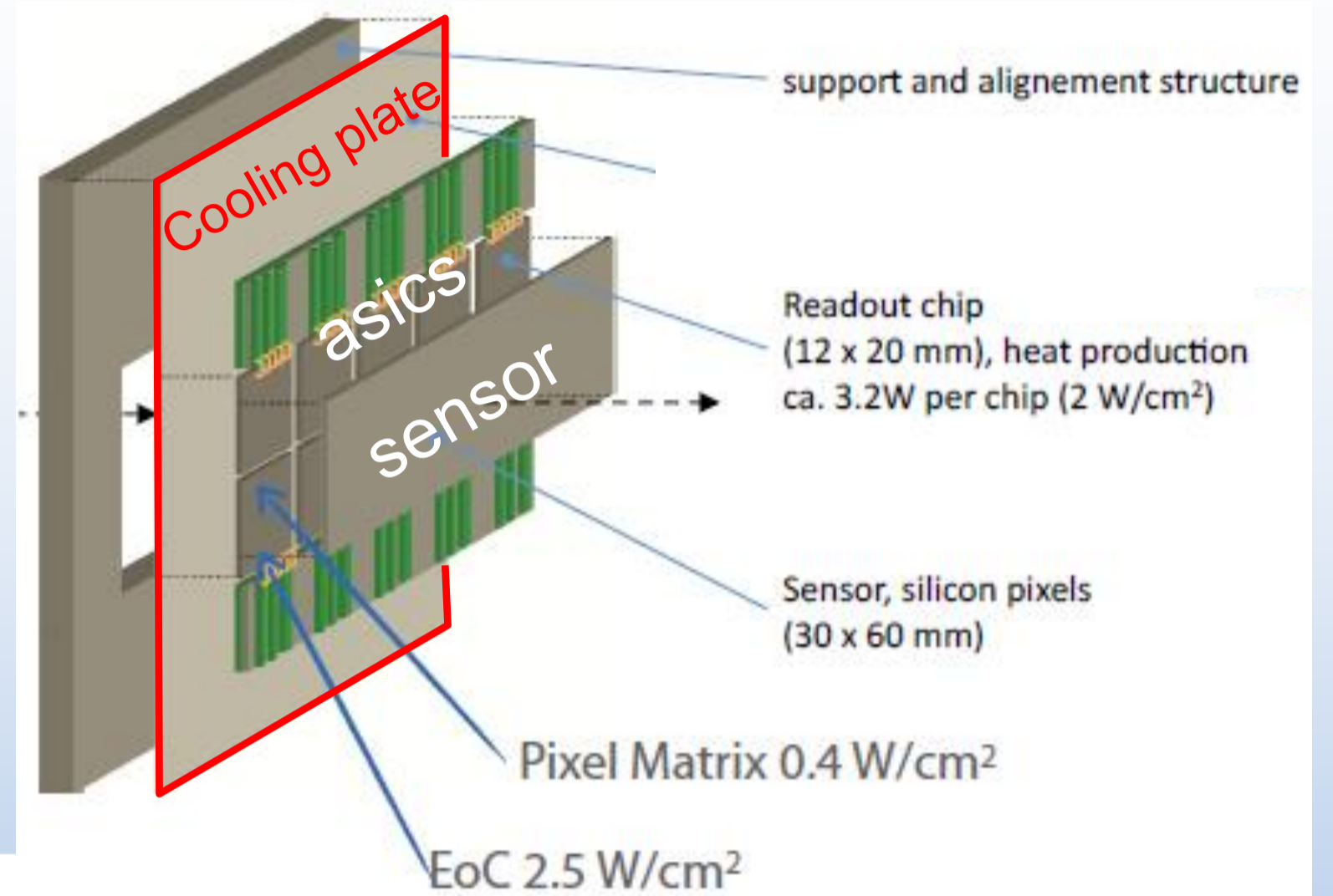


Metalization for soldering connectors

NA62 GTK: first micro channel cooling.

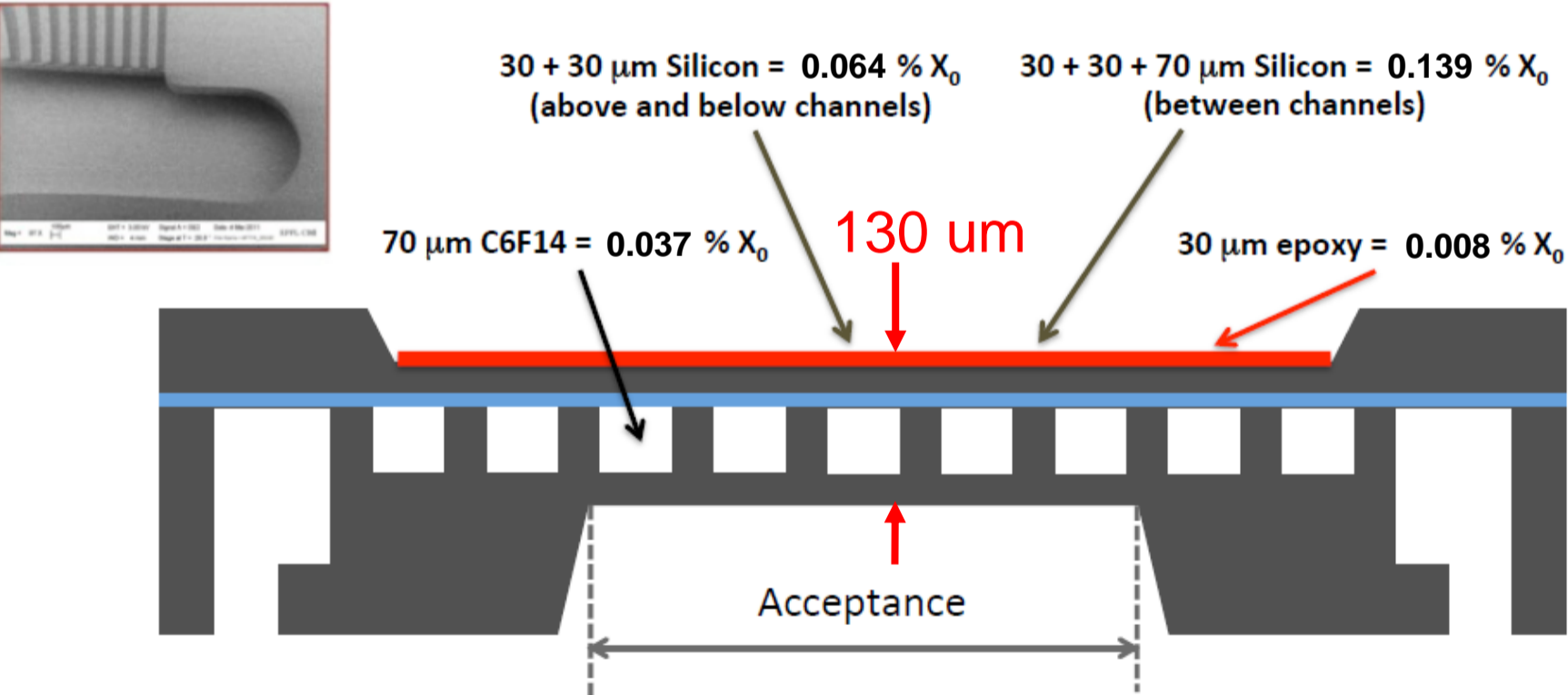


3 stations in the beam line

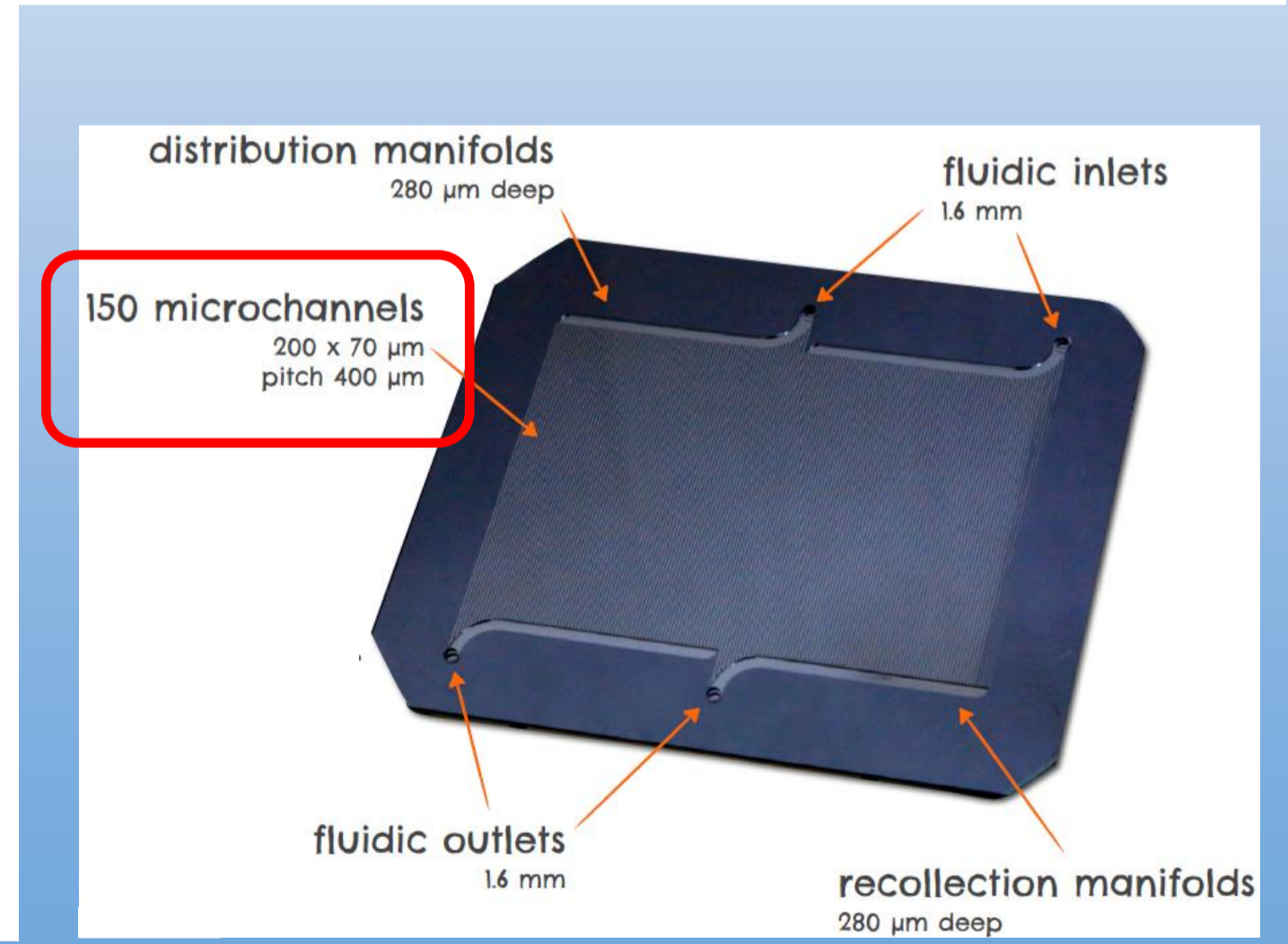


Channels = 200 x 70 μm
 Wall thickness = 200 μm
 Cover thickness = 30 μm

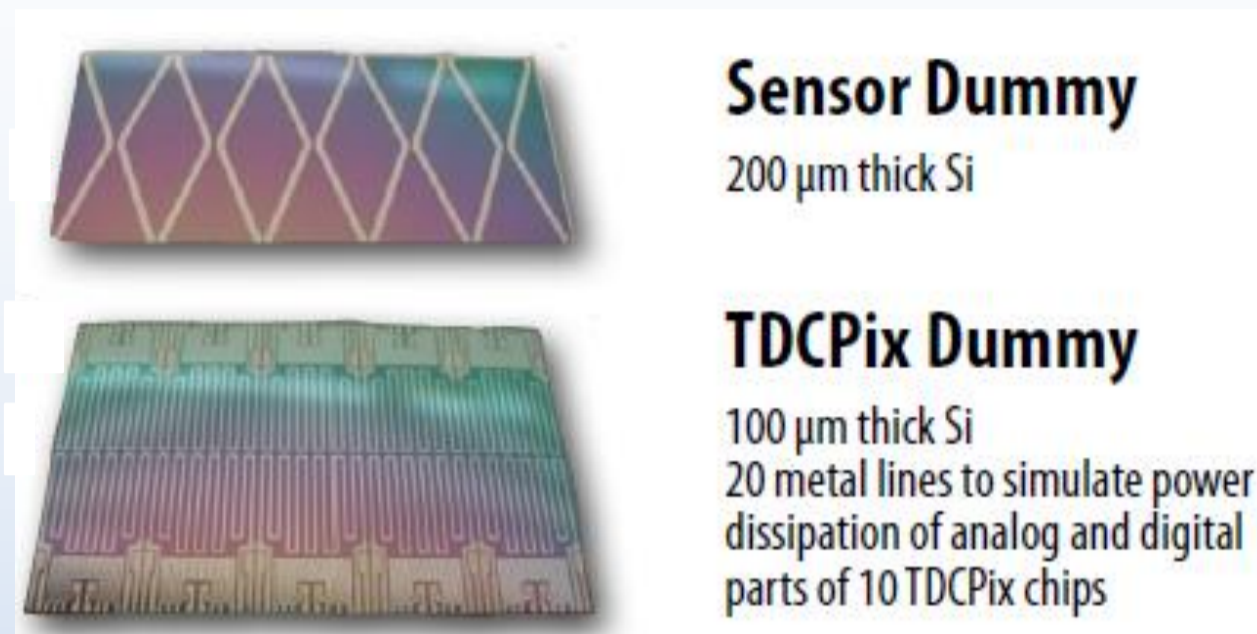
Final cross section of the **full silicon device**



Total material budget in the acceptance area = **0.13 % X_0**
 (min 0.11 % - Max 0.15 %)

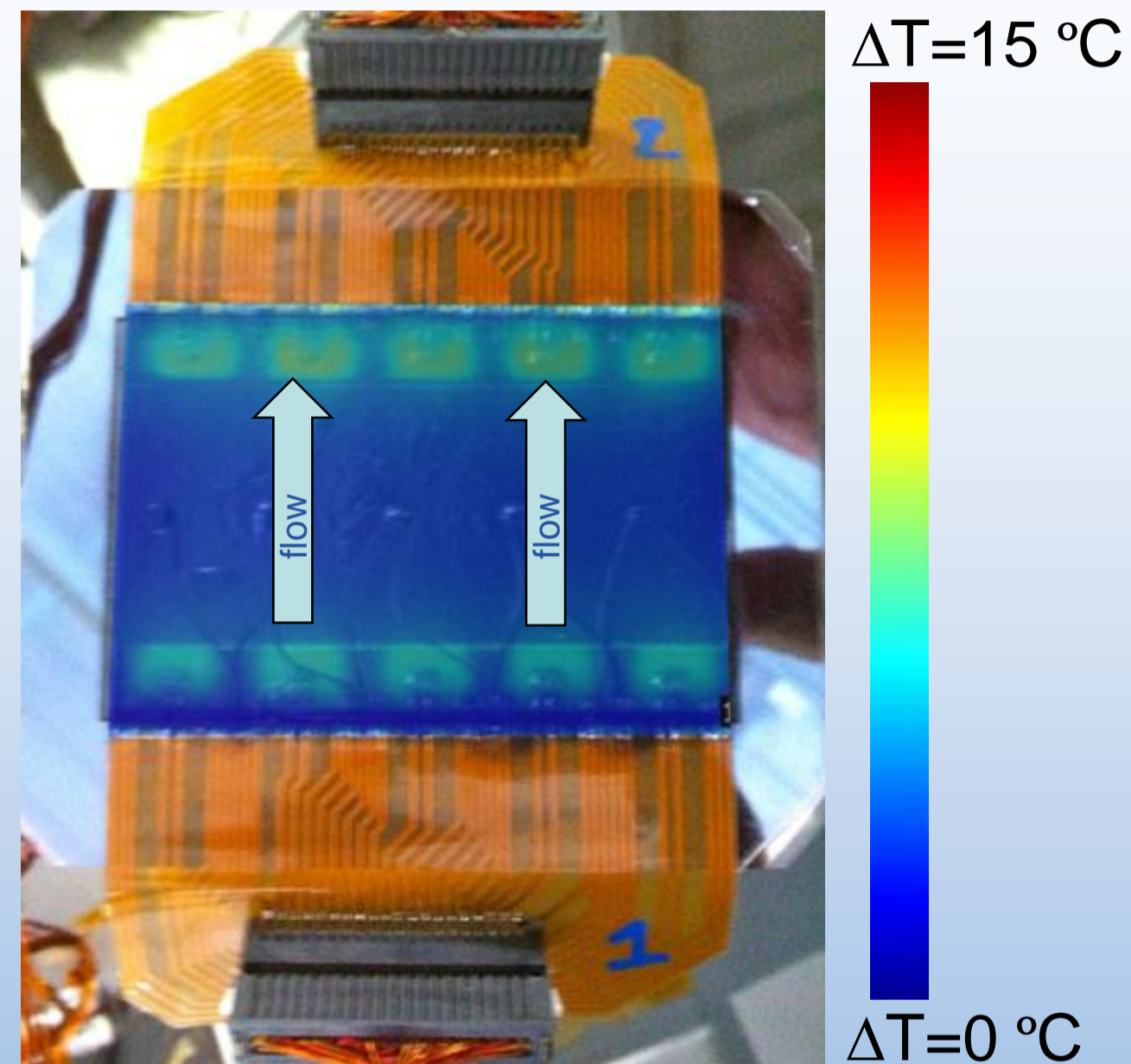
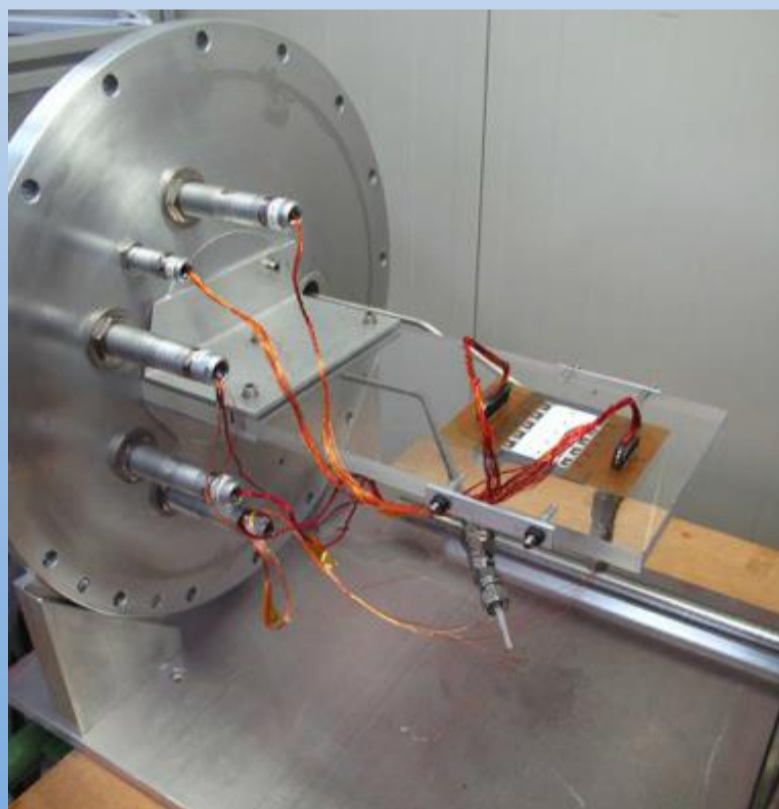


NA62 GTK: thermal performance



Dummy Si heaters

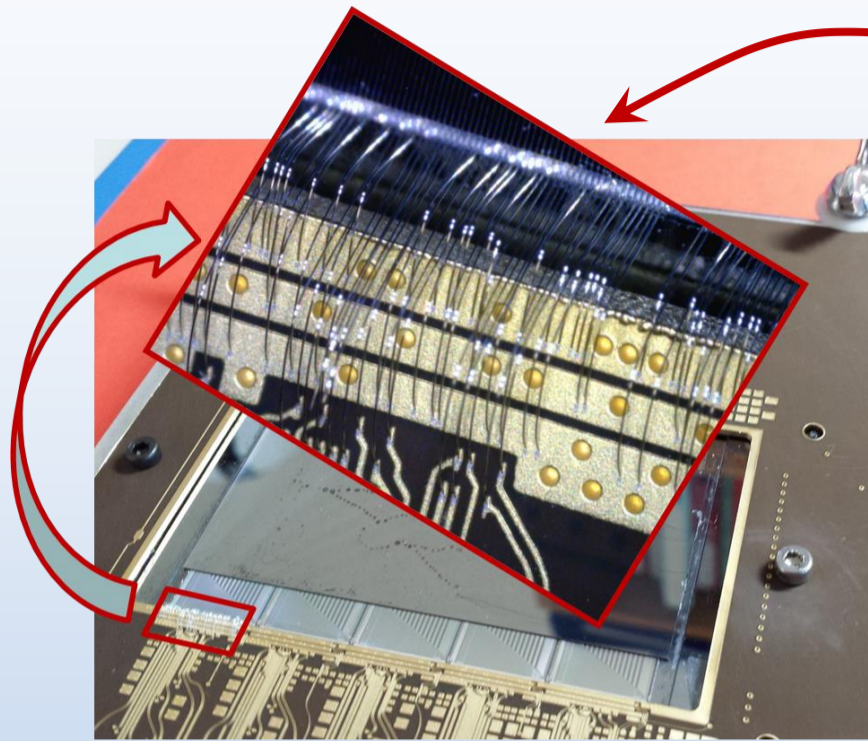
Measured in vacuum



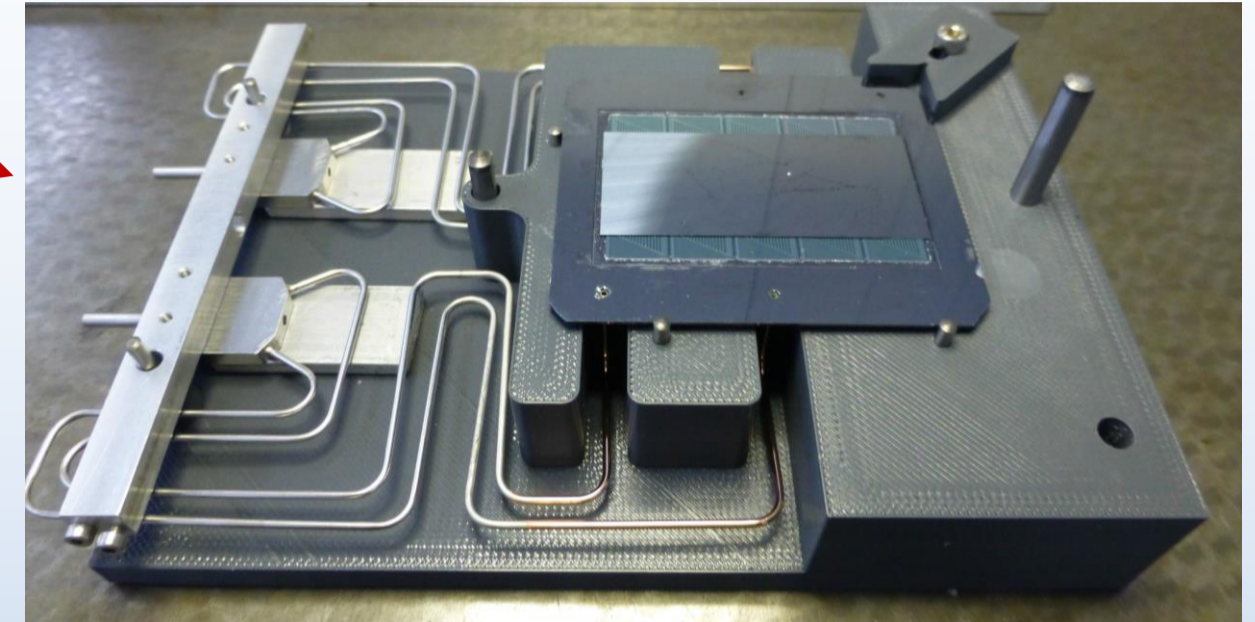
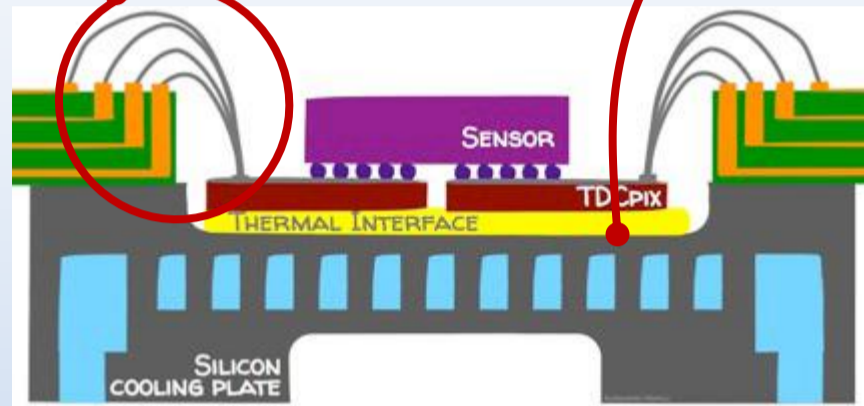
Nominal conditions:

- 20 W on ASIC, 4 W on Pixel Matrix
- liquid flow: 8 g/s C_6F_{14} @ -21°C
- $\max \Delta T_{\text{sensor}} = 1\text{ }^\circ\text{C}$,
- $\max \Delta T_{\text{chip}} = 3\text{ }^\circ\text{C}$,
- $\max \Delta T_{\text{module}} < 5\text{ }^\circ\text{C}$

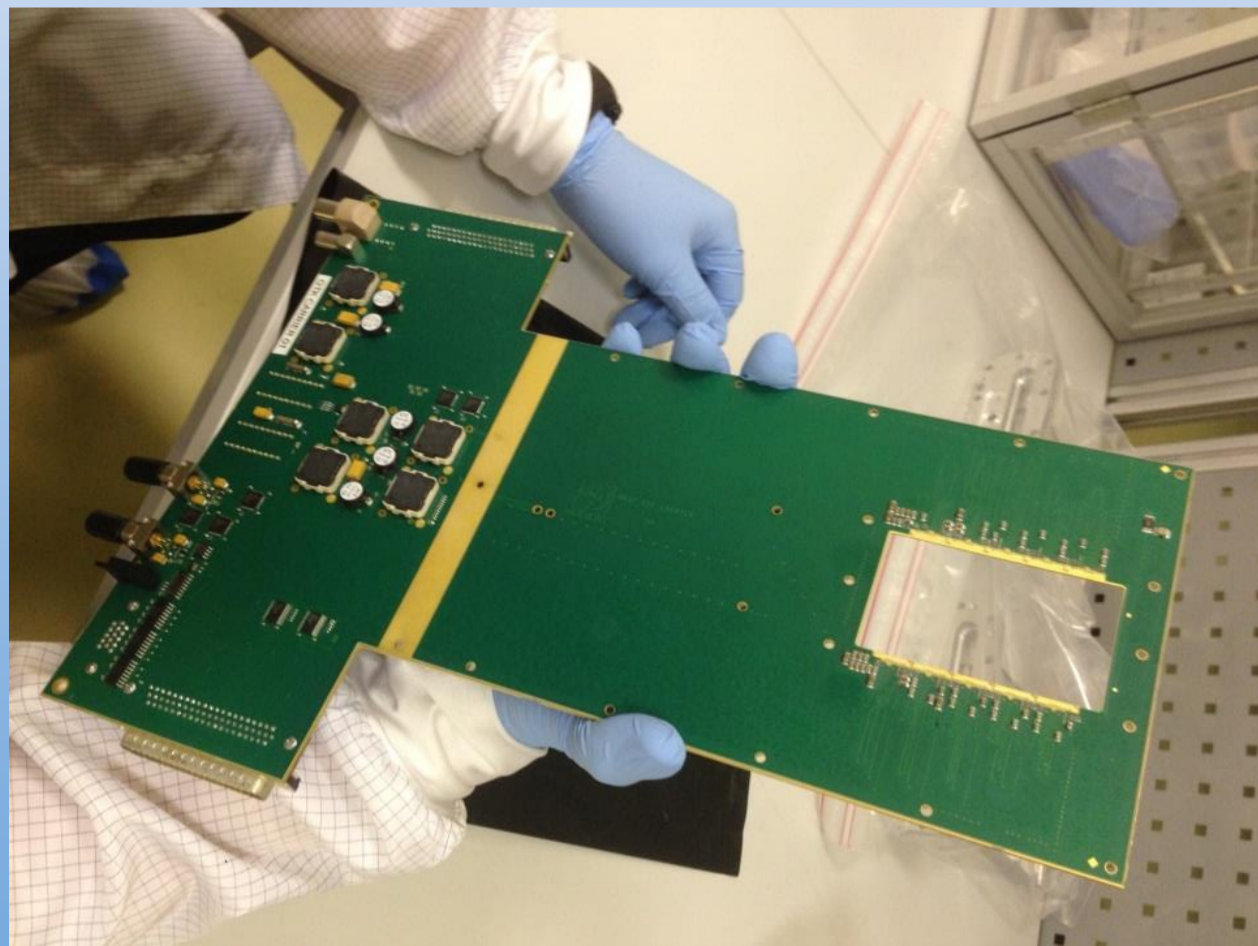
NA62 GTK: assembly of detector module



Chip to PCB wire bond



Jig for precision gluing of detector on pre-equipped μ -channel device



First GTK module in beam very soon !



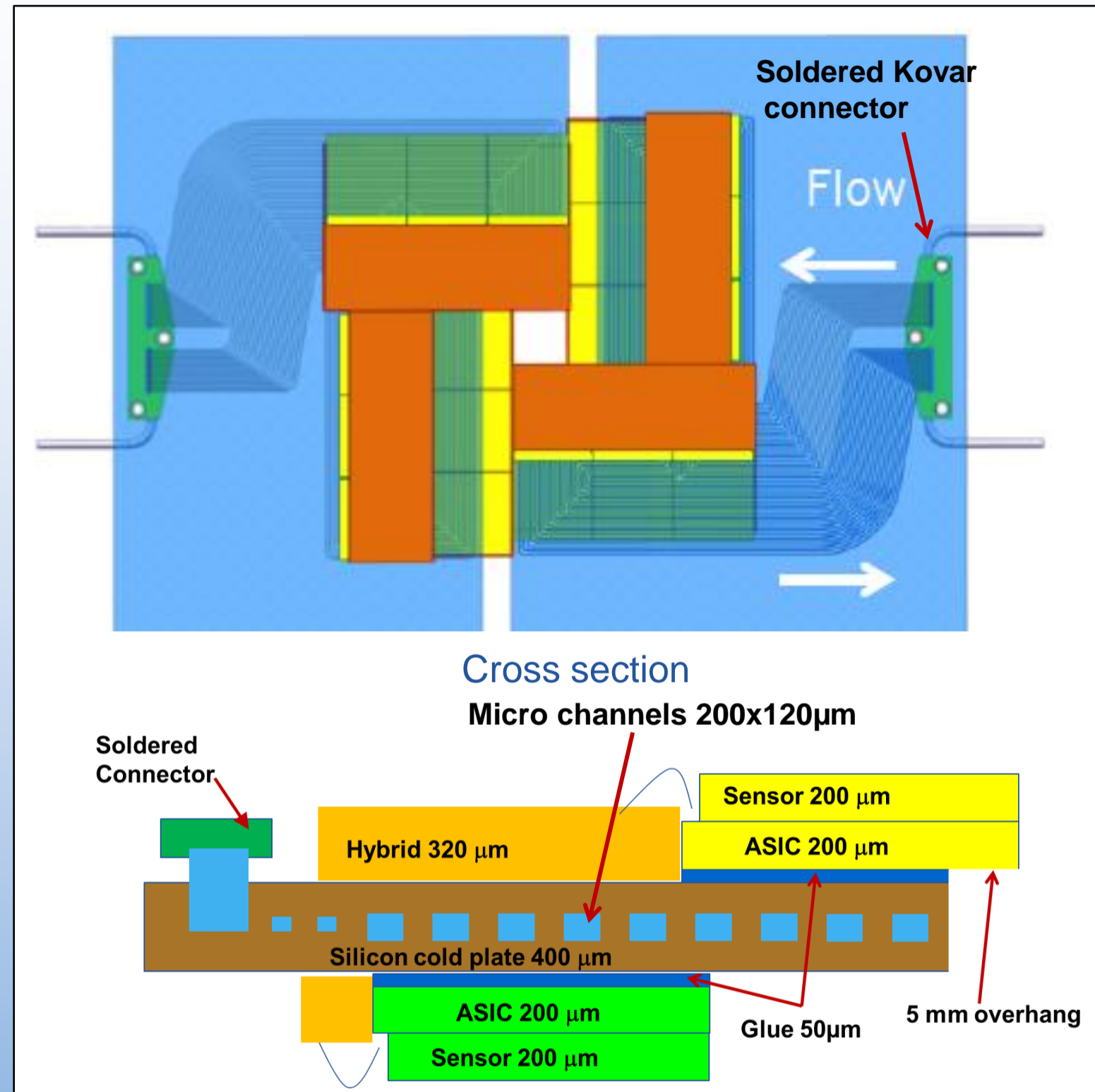
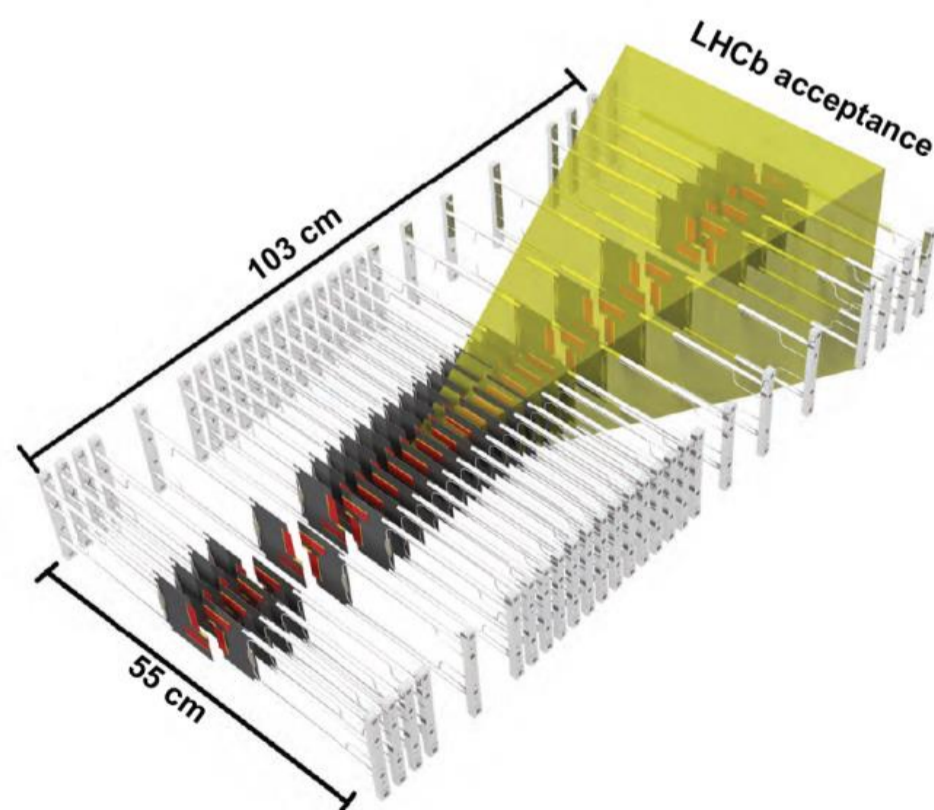
LHCb VELO: first CO₂ cooling in micro channels

Advantages of CO₂:

- High latent heat
 - Low viscosity
 - T_{sat} range from +30°C to -40°C
 - Radiation hard
 - Evaporative: stable vs load & isothermal
 - Chemical inert : no corrosion of Si
 - Non-toxic and environment friendly
- } Very well adapted to micro channels

VELO upgrade installation in 2018

- 2 detector halves with 26 modules each
- high radiation environment ($\sim 8 \times 10^{15} \text{ n}_{\text{eq}}/\text{cm}^2$)
- silicon sensor temperatures $< -20^\circ\text{C}$
- hybrid pixel detector power densities $\sim 1.8 \text{ W}/\text{cm}^2$



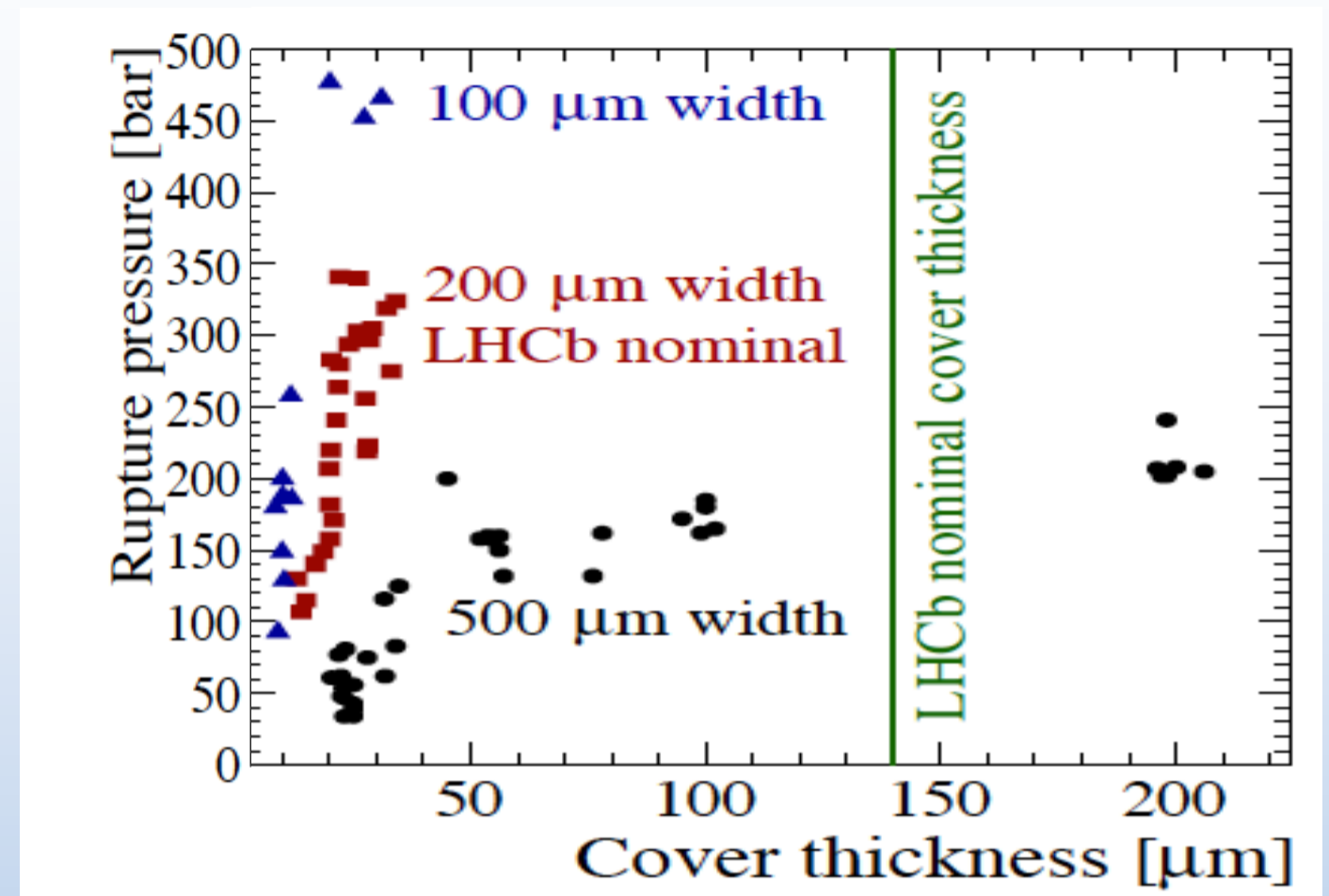
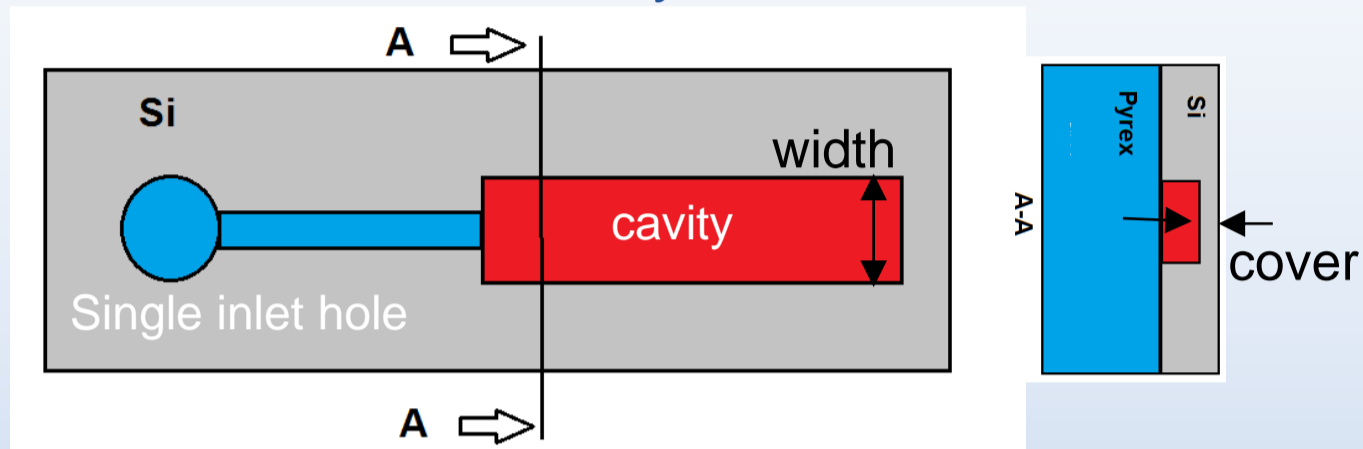
Si-Pyrex micro channel substrate prototype



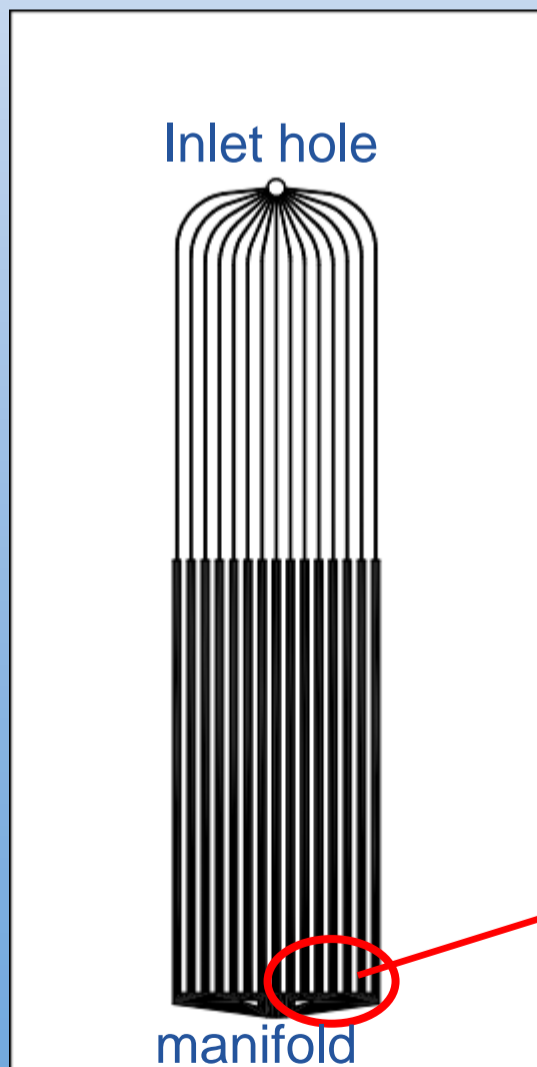
LHCb VELO: pressure tests.

Required pressure resistance is 170 bar

Test structures in Si-Pyrex



Test of multi channel & manifold in Si-Si



Hydrophilic Bonding

Intermediate oxide

vs. Hydrophobic Bonding

Si-Si fusion

Round 1

Manifolds are the weak points.

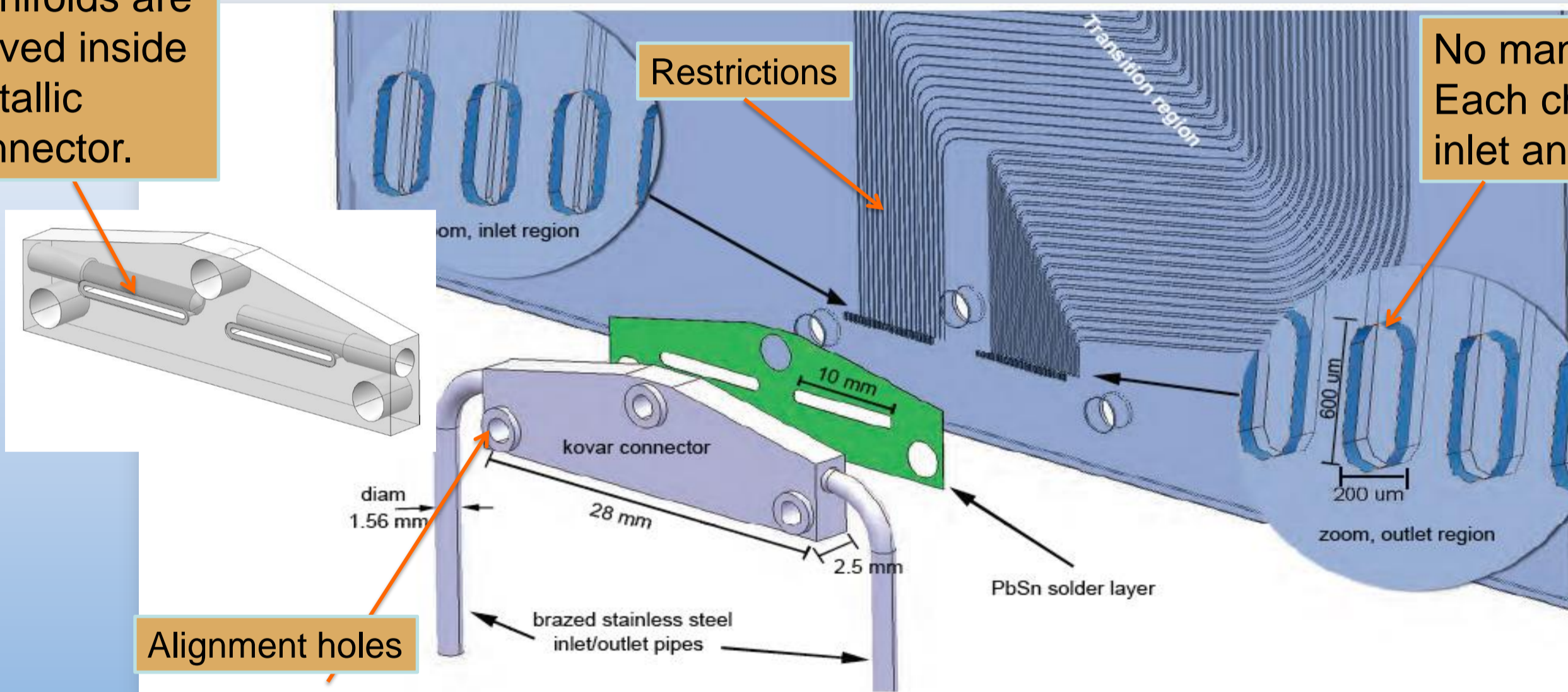
Delamination in bonding plane in channels @ ~400 bars

No delamination in bonding plane in channels > 700 bars. Only manifold breaks.

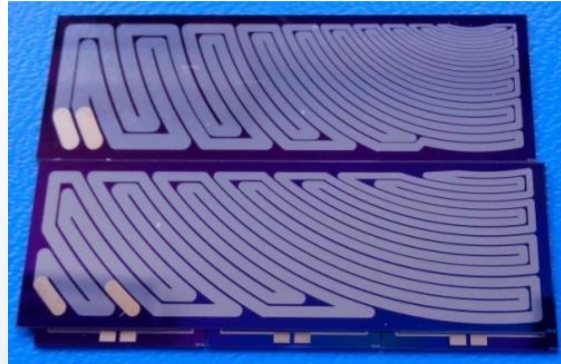
LHCb VELO: fluidic connector

Manifolds are moved inside metallic connector.

No manifolds in Silicon. Each channel has its own inlet and outlet



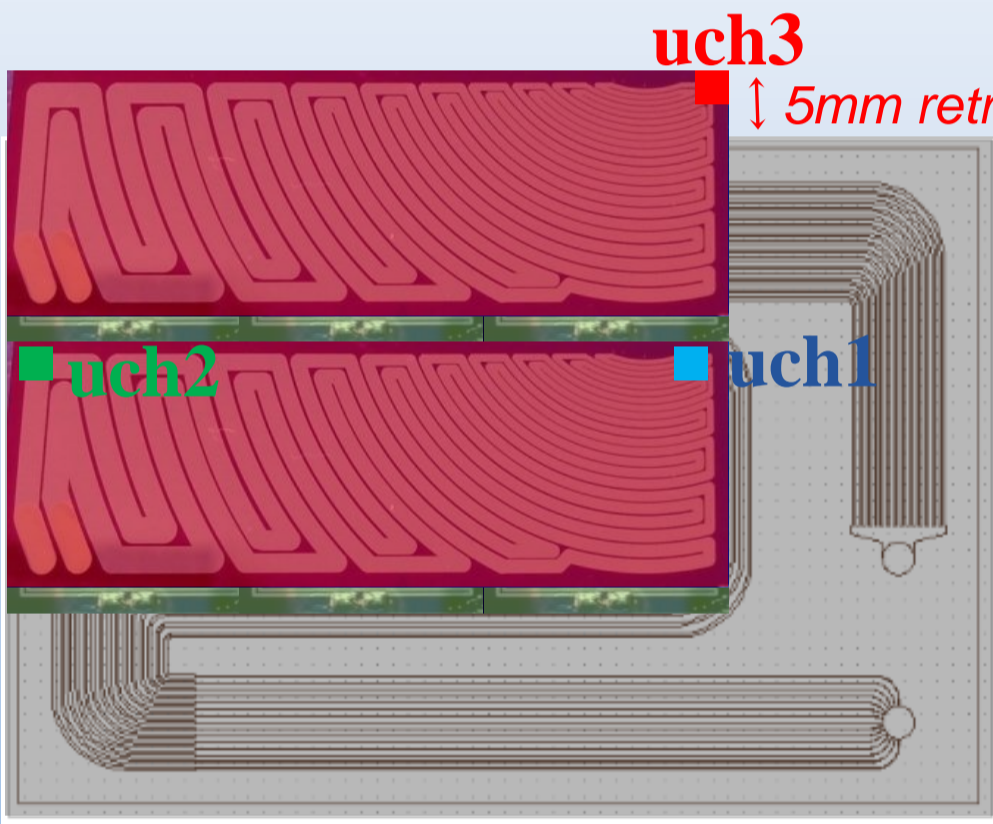
LHCb VELO: thermal performance



Silicon sensor heater



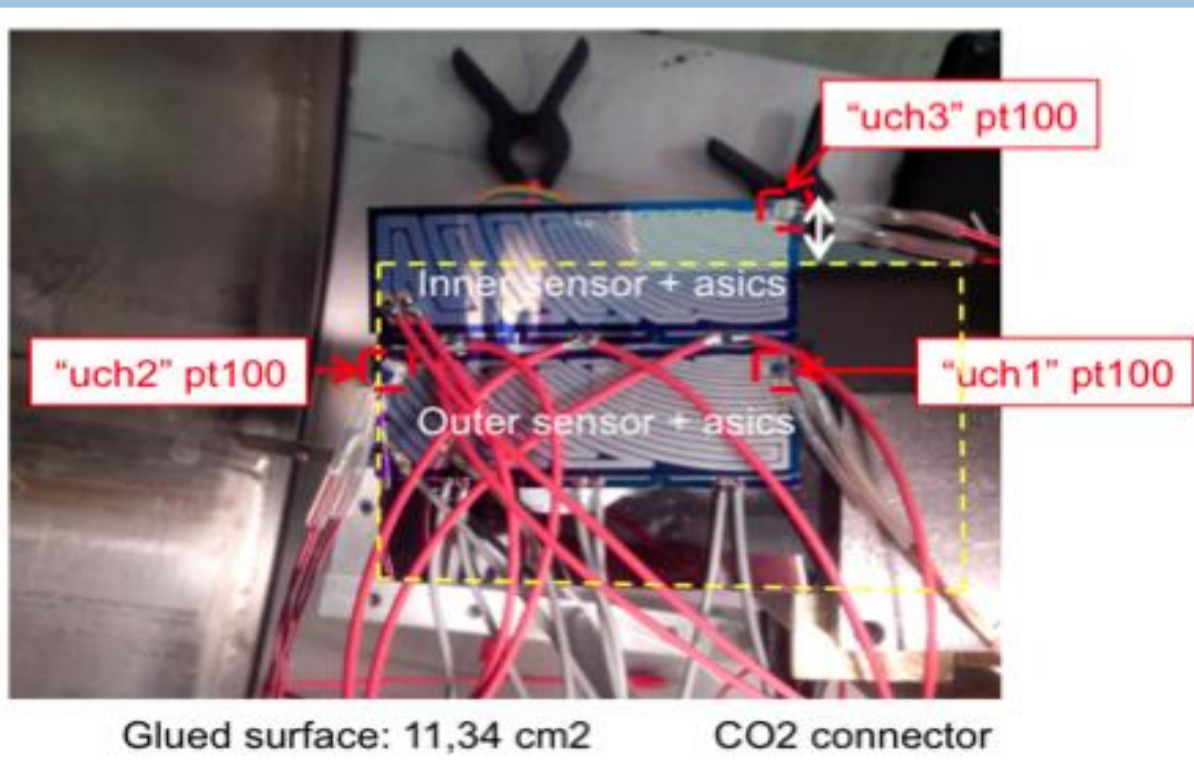
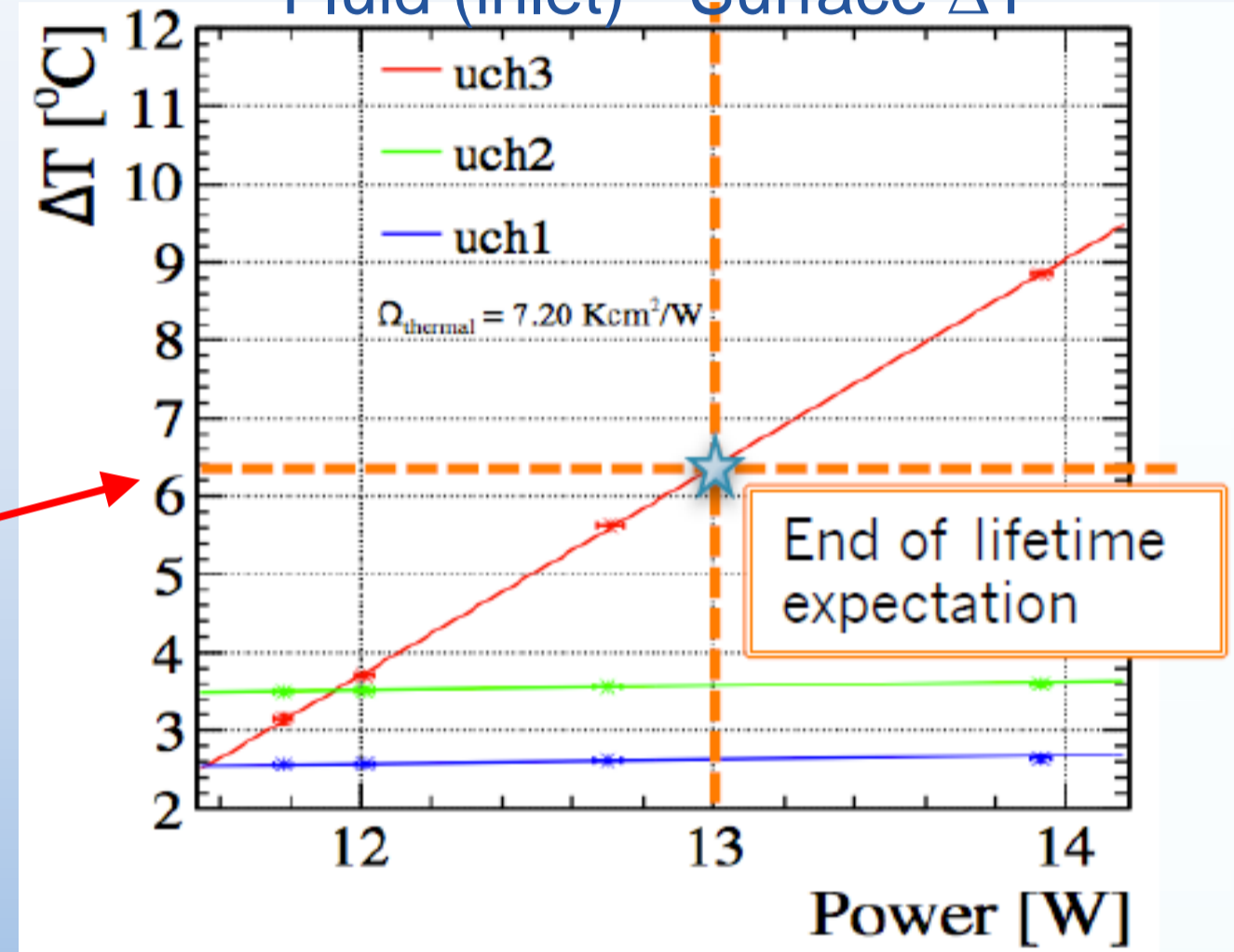
ASICS chips heaters



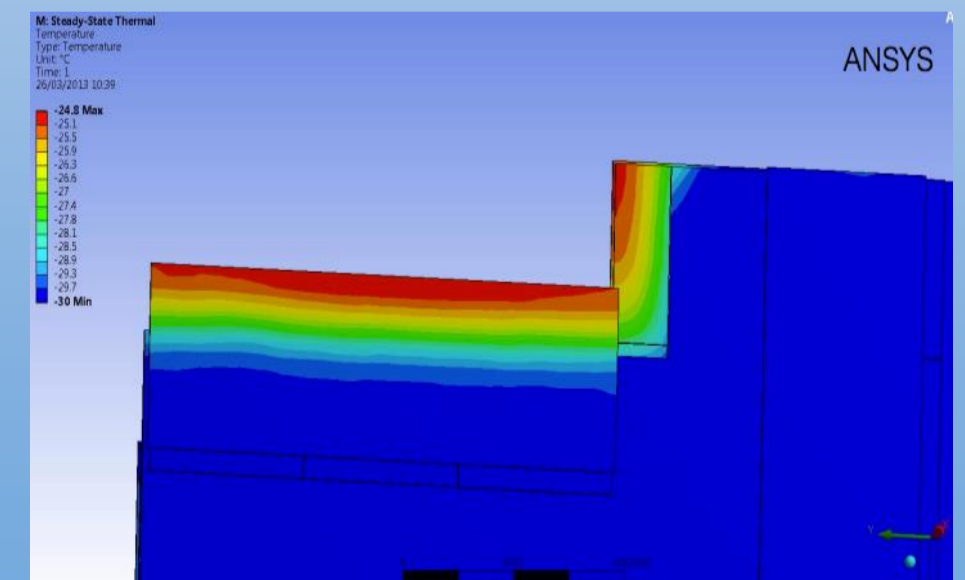
- uch1 and uch2: almost constant level
- uch3: maximum ΔT is of 7 °C at highest sensor power.

With an inlet fluid temperature of -30 °C, the detector can be held at a temperature below -20 °C with some margin.

Fluid (inlet) - Surface ΔT



Well predicted by ANSYS simulations of on-module Thermal conduction

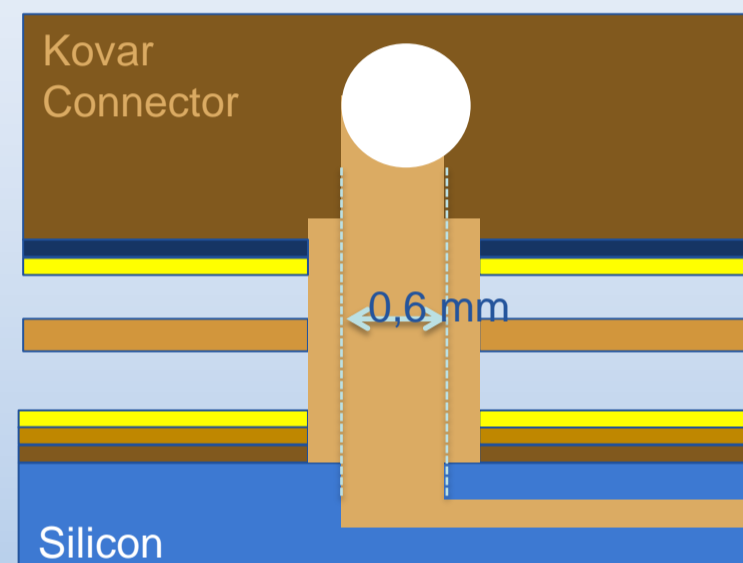
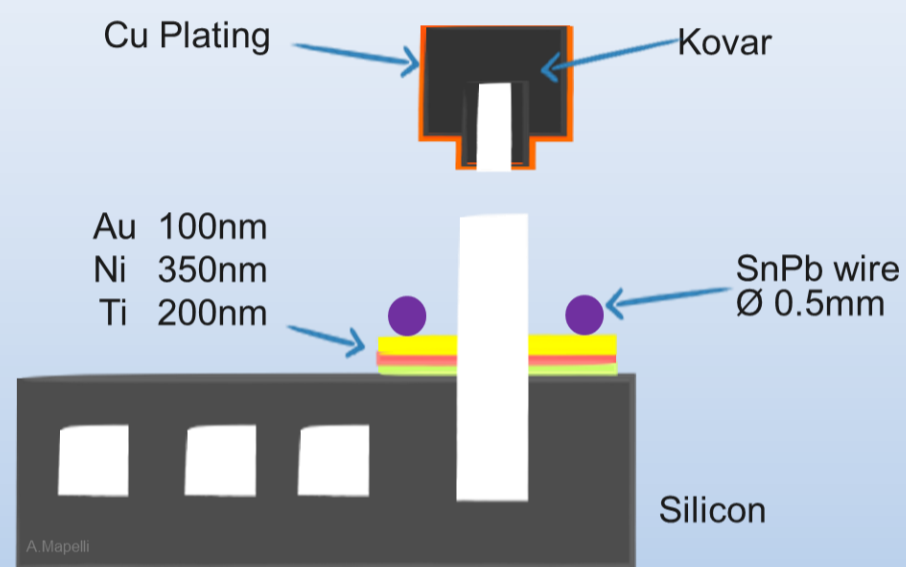


Hydraulic connections to micro channels

Flux-less SnPb reflow soldering in vacuum.

NA62 GTK : pressure 20 bar

LHCb VELO : pressure 170 bar



Ni 4 µm
Au 1 µm
SnPb 55 µm

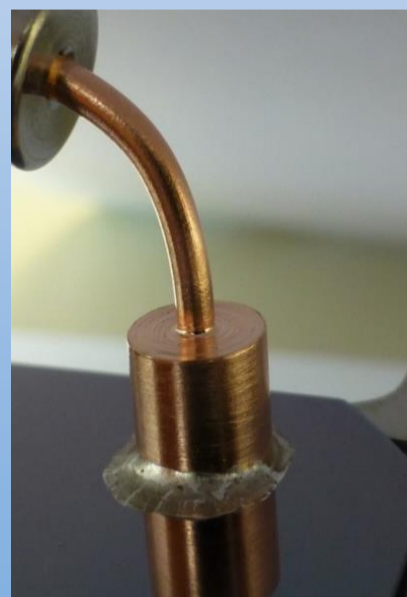
Au 1 µm
Ni 1 µm
Ti 0.2 µm



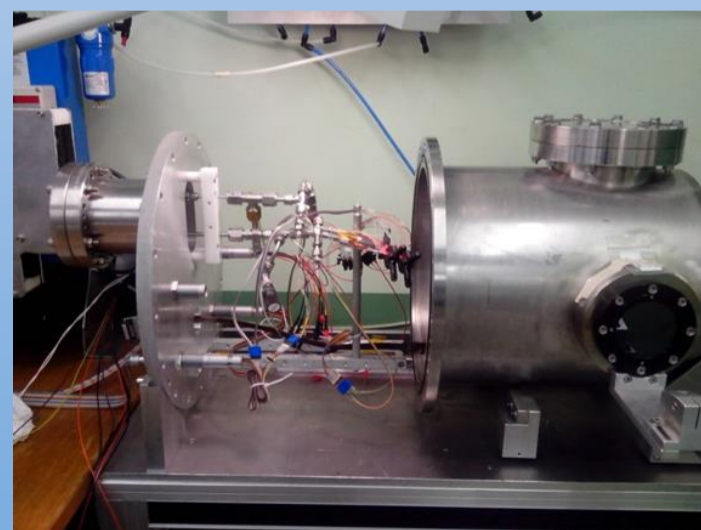
silicon

SnPb

Connector



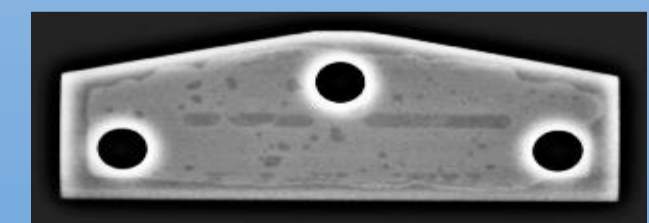
After soldering



Vacuum reflow oven.

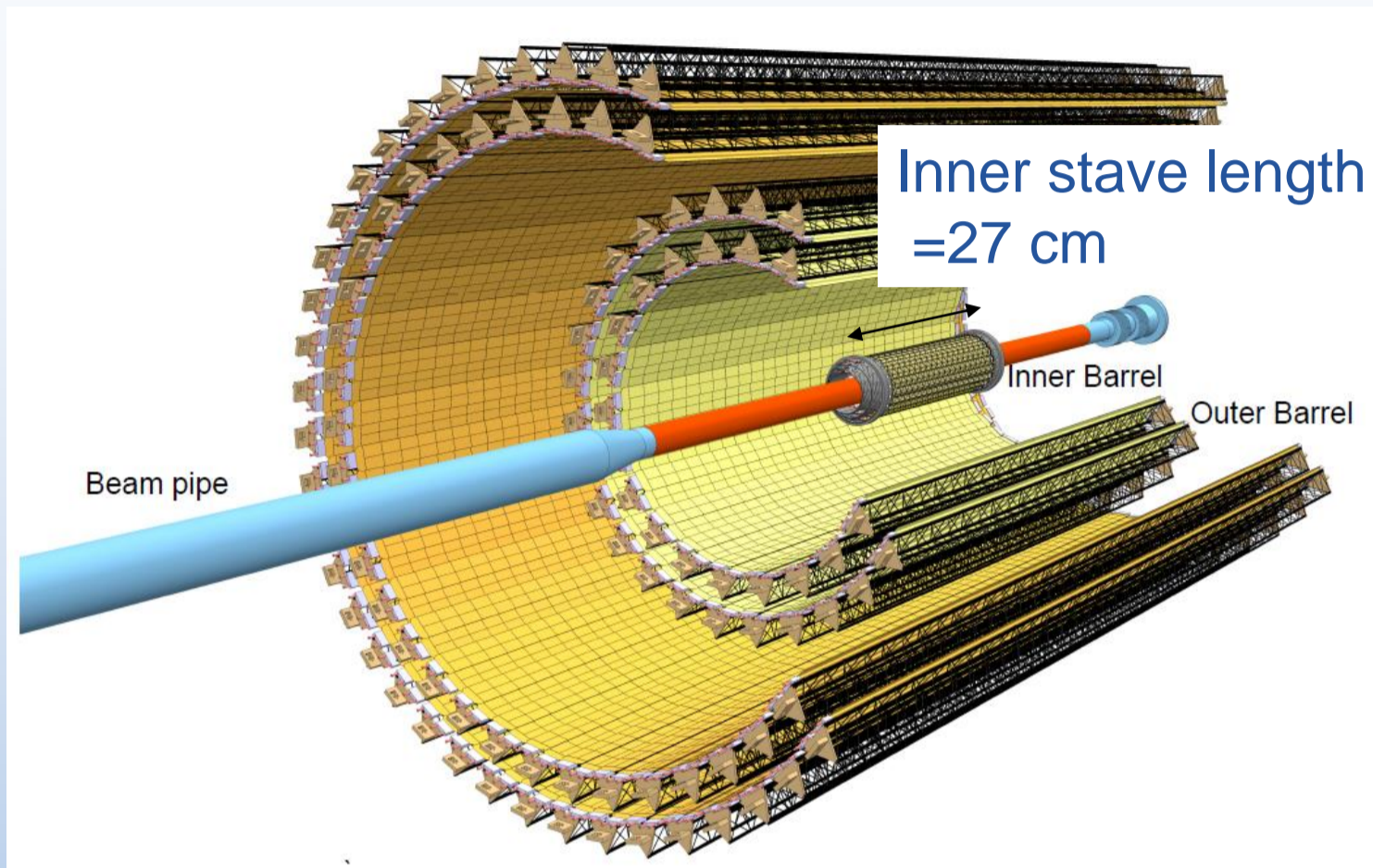


After soldering



Xray image (small voids)

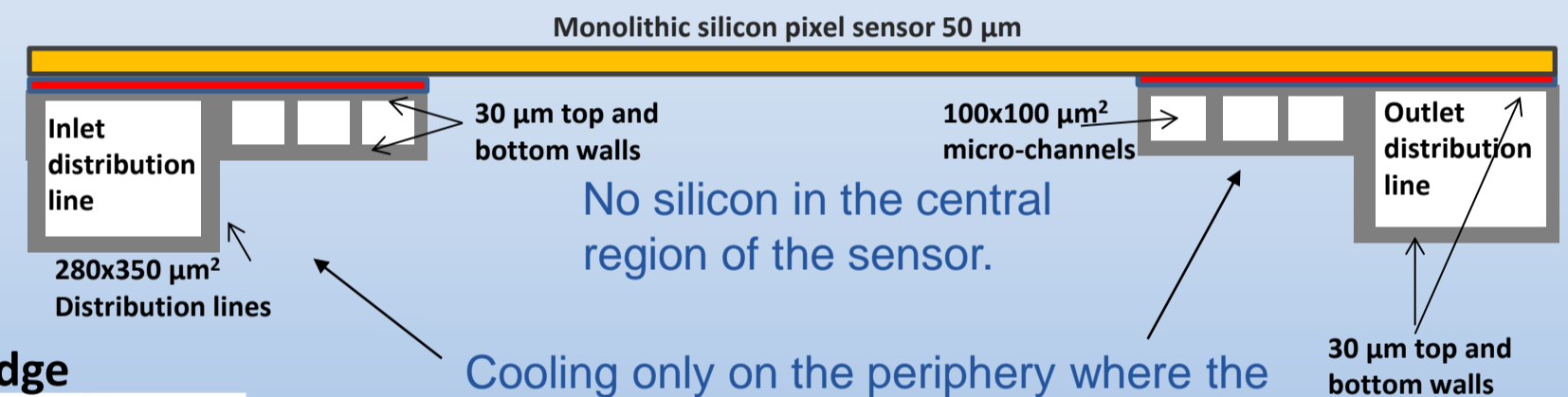
ALICE ITS upgrade option: building a stave.



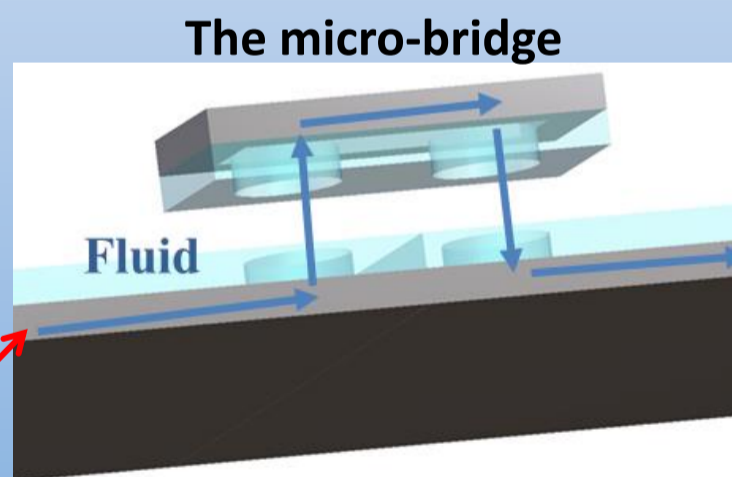
«Frame» design :



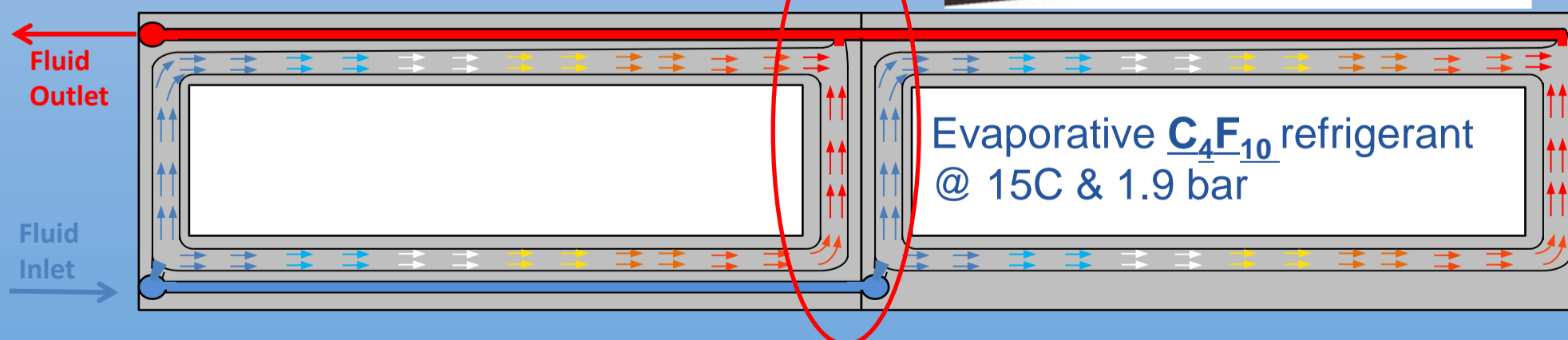
Cross-section view :



Total stave composed of 5 devices : interconnection using "micro-bridge".



- Prototyped on 4" wafers
- produced on 6" wafers

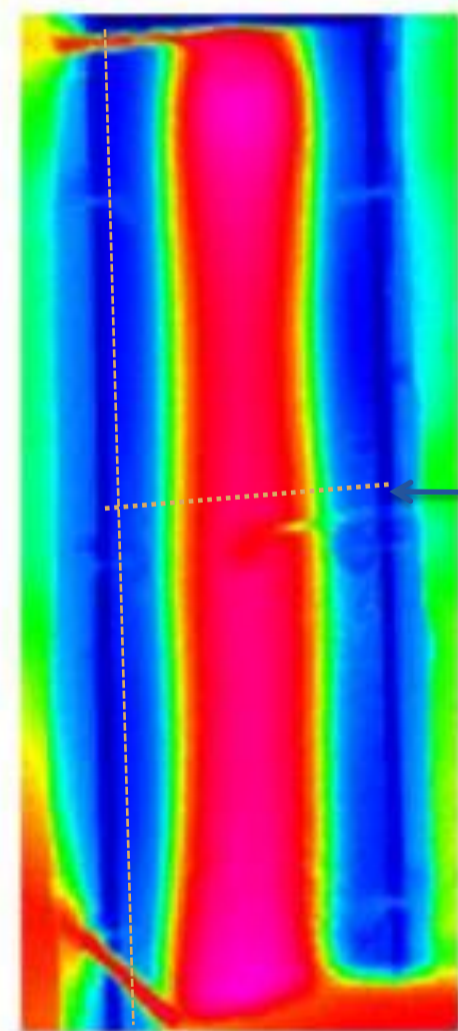


ALICE ITS: thermal measurements.

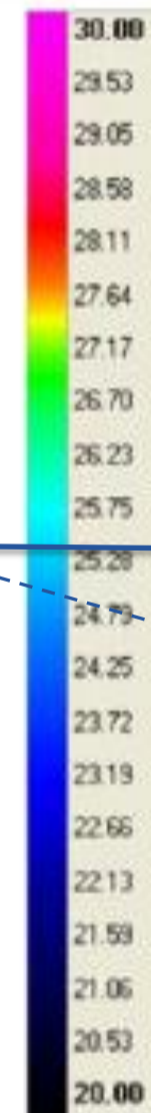
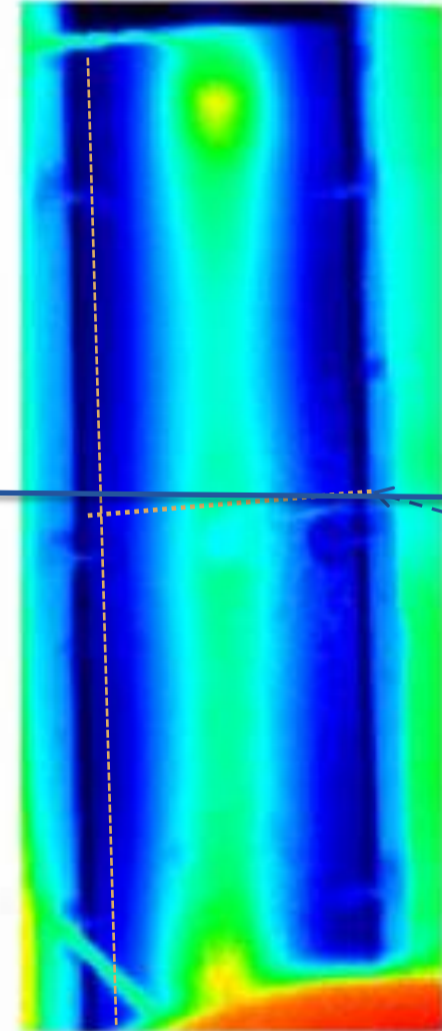
Dummy chip top surface with two electrodes and seven thermocouples



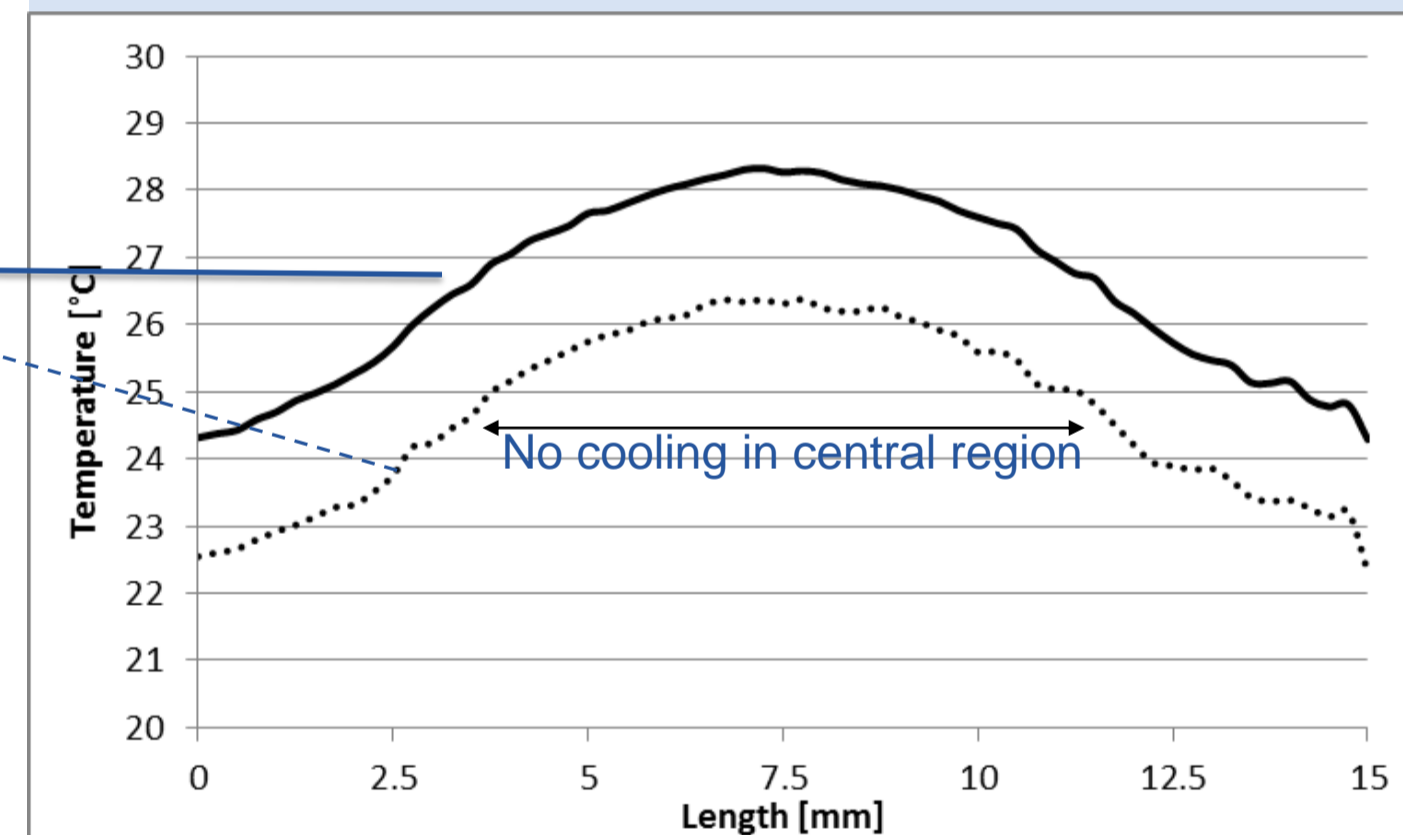
$G=300 \text{ [kg}\cdot\text{m}^{-2}\cdot\text{s}^{-1}]$
 $T_{in}=21^\circ \text{ C}$
 $T_{sat}=22.5^\circ \text{ C}$



$G=750 \text{ [kg}\cdot\text{m}^{-2}\cdot\text{s}^{-1}]$
 $T_{in}=19.5^\circ \text{ C}$
 $T_{sat}=21^\circ \text{ C}$



single frame with uniform $P=0.3\text{W/cm}^2$



Conforms to spec: $T_{max} < 30^\circ \text{ C}$ and $\Delta T_{sensor} < 5^\circ \text{ C}$
 with $T_{sat} = 21^\circ \text{ C}$ (well above the 15° C cavern dew point).

Atlas & CMS: pixel phase 2.

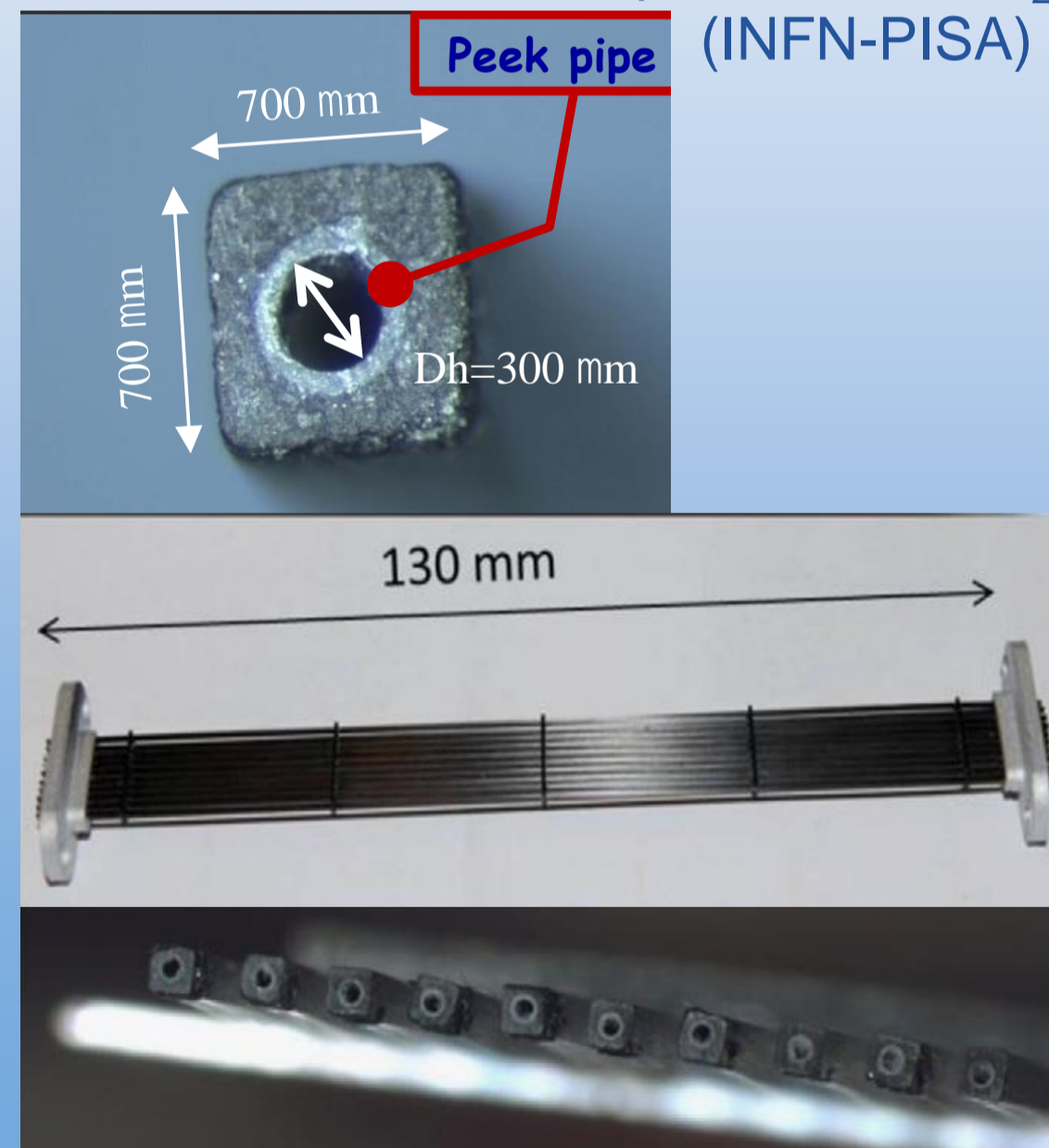
No approved projects, but some ATLAS groups are very interested in Si CO₂ micro channels and are starting exploratory developments.

Also investigating 3D ceramic printing of micro channels substrate.

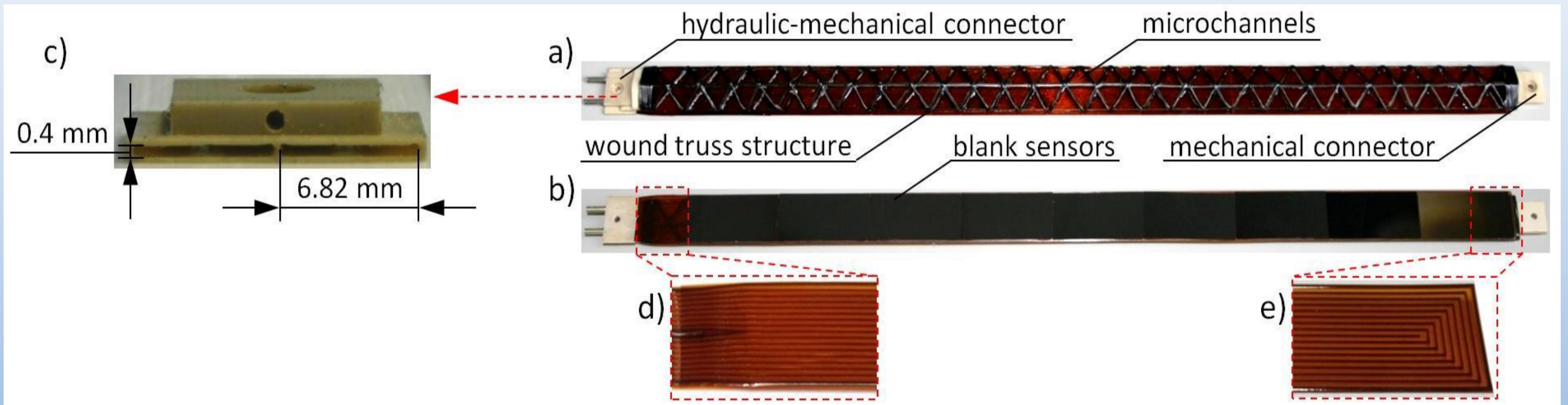
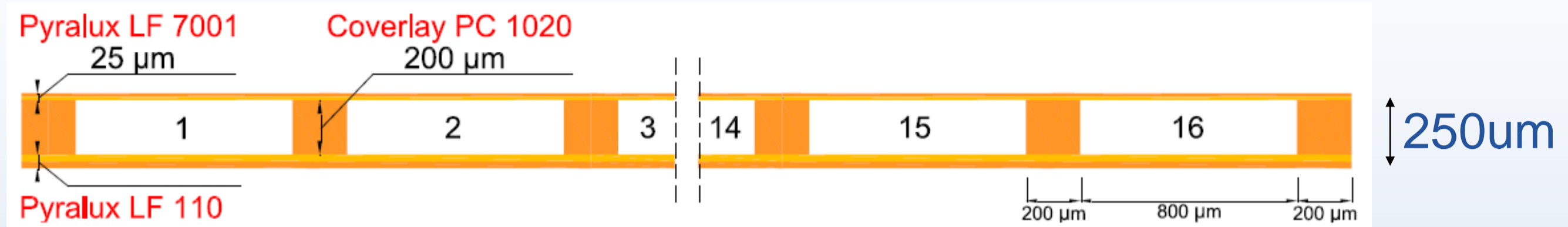
CO₂ micro channel prototype for FE-I4.



Carbon fibre reinforced plastic with CO₂ (INFN-PISA)



Polyimide micro channel.

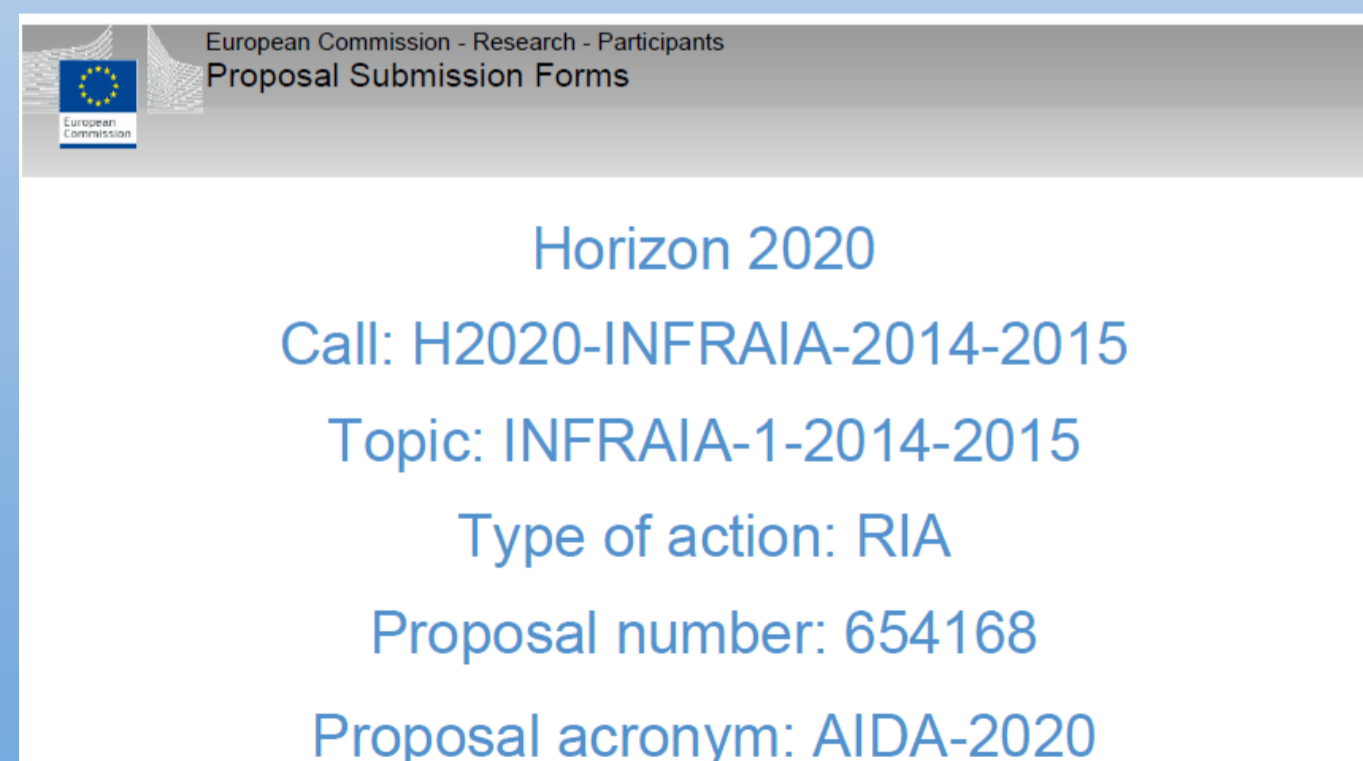


Proposal for ALICE ITS upgrade cooling.

- water or C_6F_4 mono-phase cooling at $\sim 30C$.
- Power requirement $0.5W/cm^2$
- Coolant pressure $\sim 10bar$.
- CERN & INFN development.

AIDA-2020 proposal: Work Package 9

- “New support and micro channel cooling”
 - Provide access to silicon fabrication technologies.
 - Development of a simulation library for micro fluidics and bi-phase flow in distributed micro channels.
 - Development of a standard for the connection of the devices.
 - Fabrication of prototypes to validate the models and characterise the different fabrication techniques.
 - Set up a specialised facility to implement the procedures and protocols established for characterisation and validation of models and fabrication techniques.



European Commission - Research - Participants
Proposal Submission Forms

Horizon 2020
Call: H2020-INFRAIA-2014-2015
Topic: INFRAIA-1-2014-2015
Type of action: RIA
Proposal number: 654168
Proposal acronym: AIDA-2020

Summary

- Current projects demonstrate that micro channel cooling is very well suited for thermal management of current vertex detectors:
 - high cooling performance, low X/X_0 , radiation hard, no CTE mismatch if all Si.
- It is a flexible technique:
 - Customized layout for optimal performance.
 - Different refrigerants, single-phase and two-phase.
 - Substrate choice: Si (favored), polyimide, ...
- Device size is limited by wafer dimension: construction of long staves poses challenge for interconnecting many devices.
- Connection of a macro tube to a micro channel is delicate.
 - Sn/Pb soldering seems best suited but still needs further development & consolidation.
- AIDA proposal for development of micro channels.

References

- “Development of interconnected silicon micro-evaporators for the on-detector electronics cooling of the future ITS detector in the ALICE experiment at LHC”. A. Francescon et al. 4th Micro and nano flows conference, UCL, London, 7-10 September.
- “Silicon Micro-Fluidic cooling for NA62 GTK Pixel detectors”. G. Romagnoli et al., MNE2014 Conference, Lausanne, Switzerland, 23 September 2014.
- “Evaporative CO2 micro channel cooling for the LHCb VELO pixel upgrade”. O. Augusto et al., PIXEL2014, Niagara Falls, Canada, 1-5 September 2014.
- “An innovative polyimide micro channels cooling system for the pixel sensor of the upgraded ALICE inner tracker”. G. Fiorenza et al., 5th IEEE International Workshop on Advances in Sensors and Interfaces (IWASI), 2013, p. 81-85, 10.1109/IWASI.2013.6576065.